

CONTENTS

TITLE PAGE	i
DEDICATION	ii
CERTIFICATE	iii
ACKNOWLEDGEMENTS	iv
LIST OF CONTENTS	vii

CHAPTER 1: INTRODUCTION 1-23

1.1 General Introduction	2
1.2 Magnetic Materials	3
1.2.1 Diamagnetism	3
1.2.2 Paramagnetism	4
1.2.3 Ferromagnetism	5
1.2.4 Antiferromagnetism	6
1.2.5 Ferrimagnetism	6
1.3 Ferrite Materials	9
1.3.1 Spinel Ferrites: AB_2O_4 Structure	10
1.3.2 Magnetic Interactions	11
1.4 Dielectric Materials	12
1.5 Ferroelectric Materials	13
1.6 Multiferroic Materials	15
1.8 Aim of Present Work and Thesis Outlines	17
References	21

CHAPTER 2: EXPERIMENTAL AND CHARACTERIZATION TECHNIQUES 24-64

2.1. Synthesis of Bulk Materials	25
2.2.1 Solid-State Reaction Technique	25
2.2 Thin Film Deposition: Pulsed Laser Deposition (PLD) technique	28
2.3 Characterization Technique	30
2.3.1 X-Ray Diffraction (XRD)	30
2.3.2. Near Edge X-ray Absorption Fine Structure Spectroscopy (NEXAFS)	32
2.3.3 Scanning Electron Microscopy (SEM)	34
2.3.4 Atomic Force Microscopy (AFM)	35
2.3.4.1 Contact Mode AFM	36
2.3.4.2 Tapping Mode AFM	36
2.3.5 Magnetic Force Microscopy (MFM)	37

2.3.6 Mossbauer Spectroscopy	39
2.3.6.1 Hyperfine Interactions	40
2.3.6.1.1 Isomer-shift	40
2.3.6.1.2 Electric Quadrupole Interaction	40
2.3.6.1.3 Magnetic Hyperfine Interaction	41
2.3.7 Vibrating Sample Magnetometer (VSM)	42
2.3.8 Superconducting Quantum Interferometry Device (SQUID)	43
2.3.9 Alternating Gradient Force Magnetometer (AGFM)	45
2.3.10 Electrical Transport Properties	46
2.3.11 Development of Temperature Dependent Automated Dielectric Measurement Setup	47
2.3.12 Development of Electric Field versus Polarization Measurement Setup (E-P setup)	51
2.4 Swift Heavy Ion Irradiation	55
2.4.1 Pelletron Accelerator	55
2.4.2 Materials Science Beam Line	57
2.4.3 Ion Solid Interaction	58
2.4.3.1 Thermal Spike Model	59
2.4.3.2 Coulomb Explosion Model	60
References	62

CHAPTER 3: ELECTRICAL TRANSPORT, MAGNETIC AND ELECTRONIC STRUCTURE STUDIES OF $Mg_{0.95}Mn_{0.05}Fe_{2-2x}Ti_{2x}O_{4+\delta}$ ($0 \leq x \leq 0.5$) **65-100**

3.1 Introduction	66
3.2 Results and Discussion	67
3.2.1 X-ray diffraction	67
3.2.2 Scanning Electron Microscopy (SEM)	69
3.2.3 Electrical Properties	71
3.2.3.1 Dielectric constant	71
3.2.3.2 AC Conductivity	74
3.2.3.3 Temperature dependent Capacitance measurement	77
3.2.3.4 Temperature dependence dc conductivity	78
3.2.2 Magnetic properties	80
3.2.2.1 Mossbauer spectroscopy	80
3.2.2.2 DC Magnetization Study	83
3.2.5 Near edge x-ray absorption fine structure (NEXAFS)	87
3.2.5.1 O-K edge	87
3.2.5.2 Fe $L_{3,2}$ and K edge	90
3.2.5.3 Ti $L_{3,2}$ edge	94
3.3 Conclusions	96
References	98

CHAPTER 4: STUDIES OF STRUCTURAL AND MAGNETIC PROPERTIES OF $Mg_{0.95}Mn_{0.05}Fe_2O_{4+\delta}$ THIN FILMS **101-119**

4.1 Introduction	102
4.2 Deposition Conditions for pulsed laser deposition (PLD) Thin Films	104
4.3 Results and Discussion	104
4.3.1 X-Ray Diffraction (XRD)	104
4.3.2 Magnetization study	107
4.3.3 Atomic Force Microscopy (AFM)	111
4.3.4 Magnetic Force Microscopy (MFM)	115
4.4 Conclusions	117
References	118

CHAPTER 5: STUDY OF SWIFT HEAVY ION IRRADIATION INDUCED MODIFICATION IN STRUCTURAL AND MAGNETIC PROPERTIES OF $Mg_{0.95}Mn_{0.05}Fe_2O_{4+\delta}$ THIN FILMS **120-152**

5.1 Introduction	121
5.2 Results and discussion	123
5.2.1 Irradiation Effects on Structural and Magnetic Properties of $Mg_{0.95}Mn_{0.05}Fe_2O_4$ thin films deposited on Pt-Si substrate	123
5.2.1.1 X-ray Diffraction (XRD)	123
5.2.1.2 Atomic Force Microscopy (AFM)	125
5.2.1.3 DC Magnetization	133
5.2.1.3 Magnetic Force Microscopy (MFM)	135
5.2.2 Irradiation Effects on $Mg_{0.95}Mn_{0.05}Fe_2O_4$ thin films grown on ITO substrate: Structural and Magnetic Properties	136
5.2.2.1 X-ray Diffraction (XRD)	136
5.2.2.2 Atomic Force Microscopy (AFM)	138
5.2.2.3 DC Magnetization	144
5.2.2.3 Magnetic Force Microscopy (MFM)	148
5.3 Conclusions	149
References	151

CHAPTER 6: SUMMARY AND FUTURE SCOPE **153-159**

6.1 Scope of the Present Work	154
6.2 Effect of Ti^{4+} substitution in $Mg_{0.95}Mn_{0.05}Fe_2O_4$ material	154
6.3 Thin Films deposited of $Mg_{0.95}Mn_{0.05}Fe_2O_4$ on Pt-Si and ITO substrate	156
6.4 Effect of 200 MeV Ag^{15+} ions irradiation on the thin films of $Mg_{0.95}Mn_{0.05}Fe_2O_4$ deposited at different substrates	157
6.5 Future Scope	159

PUBLICATIONS IN PEER REVIEWED JOURNALS	160
LIST OF PAPERS PRESENTED IN CONFERENCES/SYMPOSIA	162